

- 18P1-01 Power Source Improvement for Atmospheric Plasma Jet Production**
¹Hiroto Matsuura, ¹Trung Nguyen Tran, ¹Yoshiki Matsui and ²Yuichiro Takemura
¹Osaka Prefecture University
²Kindai University
- 18P1-02 Oxygen Radical Measurement of Atmospheric Pressure Microwave Plasma Employing Vacuum Ultraviolet Absorption Spectroscopy**
Hansin Bae, Yosuke Koike, Hirotsugu Koma, Haruka Suzuki and Hiroataka Toyoda
Nagoya University
- 18P1-03 Time-resolved Measurement of Cross-Sectional Structure of a Narrow Gap Plasma Produced by an Atmospheric Pressure Microwave Discharge**
Yoshi Baba, Haruka Suzuki and Hiroataka Toyoda
Nagoya University
- 18P1-04 Hydrogen Recycling Properties of Tin Wall in DC Glow Hydrogen Plasma**
¹Kota Tamura, ¹Haruka Suzuki, ¹Hiroataka Toyoda and ²Junichi Miyazawa
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- 18P1-05 Application of Atmospheric-Pressure Plasma Treatment to Coat Ti-Alloy Orthodontic Wire with White Oxide Layer**
¹Naho Mitsuishi, ²Eri Miura-Fujiwara, ¹Motoko Yamada, ¹Tadachika Chiba, ¹Hisashi Sato,
¹Yoshimi Watanabe, ³Michiko Ito, ³Seigo Takashima, ⁴Masaaki Nakai and ⁵Toshikazu Akahori
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⁵Meijo University
⁶Kyushu University
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⁸Osaka University
⁹Nagoya University
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- 18P1-06 High Density and Low Temperature Nitrogen Plasmas for Nitrogen Atom Source**
¹Noriyasu Ohno, ¹Koji Asaoka, ¹Shin Kajita, ¹Hirohiko Tanaka and ²Yuki Hayashi
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- 18P1-07 Bactericidal Effect of Surface Dielectric Barrier Discharge with Various Voltage and Treatment Time**
Chang Shu-Chien and Hsieh Jang-Hsing
Ming Chi University of Technology, New Taipei City, Taiwan
- 18P1-08 Hybrid DC+ HIPIMS Magnetron Sputtering Deposition of Cu Films**
Viacheslav Semenov, Vladimir Oskirko, Alexander Zakharov, Sergey Rabotkin,
Igor Ionov and Andrey Solovyev
Institute of High Current Electronics SB RAS

- 18P1-09 **Langmuir Probe Characterization of Annular DC Magnetron Plasmas with Al, Ti and Ti-Al Targets**
Jarl Tynan Collado, Christian Lorenz Mahinay, Paz Victoria Ramos, Franulfo dela Cruz, Rafael Alexander Carreon and Juan Gabriel Troncales
Ateneo de Manila University
- 18P1-10 **Study on Soil Disinfection using Ozone Water**
¹Tatsuya Seto, ¹Daigo Yasutake, ¹Shota Kawazoe, ²Noriko Horibe, ²Kazuhiro Nagahama, ²Shin-ichi Aoqui and ¹Fumiaki Mitsugi
¹Kumamoto University
²Sojo University
- 18P1-11 **Visualization of the Sound Pressure Distribution of Acoustic Wave Emitted by Surface Discharge using Optical Wave Microphone CT Scanning System**
¹Sho Honda, ¹Ryo Kikuchi, ²Paiva Victoria, ³Toshiyuki Nakamiya and ³Yoshito Sonoda
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²Instituto Tecnológico de Aeronautica
³Shin-Giken Co., Ltd.
- 18P1-12 **Diagnostics and Monitoring of Low Temperature Plasma by Multipole Resonance Probe**
Natthapong Jampaiboon, Chatchai Sirithipvanich, Worawan Bhanthumnavin and Boonchoat Paosawatanyong
Chulalongkorn University
- 18P1-13 **Nitriding Treatment using Active Screen Plasma and Its Evaluation**
¹Susumu Ichimura, ¹Seigo Takashima, ²Ippei Tsuru, ²Daichi Ohkubo, ²Hideaki Matsuo and ²Mineo Goto
¹Nagoya Industries Promotion Corporation
²Nakanihon-Ro Kogyo Co., Ltd.
- 18P1-14 **Neutron Irradiation Effects on Bubble Formed Tungsten Material**
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³Nagoya University
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- 18P1-15 **Plasma Polymerization of Poly (methyl-methacrylate) and Cyclopropylamine Inside the Inner Surface of Silicone Tube using Capacitively Coupled Radio Frequency Plasma Reactor**
Himanshu Mishra, Nima Bolouki and Hsieh Jang Hsing
Ming Chi University of Technology
- 18P1-16 **Control of SiO₂/InAlN Interface by Plasma Surface Oxidation**
Shouhei Kitajima and Masamichi Akazawa
Hokkaido University
- 18P1-17 **Fabricating Improved Fit Soft Contact Lenses with Various Monomers**
Zhong-Rui Wu, Meng-Jiy Wang and Jinn-Hsuan Ho
National Taiwan University of Science and Technology

- 18P1-18 Enhanced Growth or Fiberform Nanostructures by He Plasma Irradiation**
¹Shin Kajita, ¹Shota Kawaguchi, ²Naoaki Yoshida, ¹Tatsuki Okuyama, ¹Tomohiro Nojima, ¹Hirohiko Tanaka and ¹Noriyasu Ohno
¹Nagoya University
²Kyushu University
- 18P1-19 Characteristics of HiPIMS Driven by Spiker-sustainer Pulses for DLC Deposition**
¹Koichi Takaki, ¹Mutsumi Takahashi, ¹Katsuyuki Takahashi, ¹Seiji Mukaigawa and ²Ken Yukimura
¹Iwate University
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- 18P1-20 Plasma-Modified Zeolites as Adsorbents of Volatile Organic Compounds**
Fatima Jenina Arellano, Eleanor Olegario and Magdaleno Jr. Vasquez
University of the Philippines-Diliman
- 18P1-21 Fluorine-plasma Etching Behavior of Sputter-deposition Yttrium Fluoride Film**
Wei-Kai Wang, Yu-Xiu Lin and Yi-Jie Xu
Da-Yeh University
- 18P1-22 Comparison of Plasma Surface Functionalized 3D PCL and 3D PCL/ Beta-TCP Scaffold on Bone Regeneration Efficiency**
¹Min-Suk Kook, ²Byung-Hoon Kim, ¹Myung-Sun Kim, ¹Eun-Ji Lee and ¹Gwang-Min Heo
¹Chonnam National University
²Chosun University
- 18P1-23 Decolorization of Amaranth Aqueous Solution by Atmospheric-pressure Plasma Jet Irradiation**
Hiroshi Kuwahata, Daisuke Sato, Yusuke Kezuka and Yoshiki Oda
Tokai University
- 18P1-24 Effect of Bipolar Pulsed Parameters on The Microstructure and Corrosion Resistance of AZ31 Magnesium Alloys Treated by Plasma Electrolytic Oxidation**
¹Chien-An Yen, ^{1,2}Jyh-Wei Lee and ^{2,3}Bih-Show Lou
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- 18P1-25 The Performance of Three-Dimensionally Integrated Micro Solution Plasma Assisted with Argon Micro-Bubble**
Reiya Nakagawa, Hiroto Masunaga, Jun-seok Oh and Tatsuru Shirafuji
Osaka City University
- 18P1-26 The Influence of Pulse Voltage Polarity on Au-Nanoparticle-Embedded Film Formation on Aqueous Solution in contact with DBD**
¹Shunta Hirano, ¹Shiori Azuma, ¹Yusuke Nakamura, ²Toshiyuki Isshiki, ¹Jun-seok Oh and ¹Tatsuru shirafuji
¹Osaka City University
²Kyoto Institute of Technology

- 18P1-27 **AC Glow Discharge in Liquids: Its Influence and Ability to Silver Nanoparticles Synthesis**
Phuoc Thai, Shinnosuke Abe, Kenichiro Kosugi, Nobuo Saito, Kazumasa Takahashi, Toru Sasaki and Takashi Kikuchi
Nagaoka University of Technology
- 18P1-28 **Carbon Nanoflakes Involving Fe-N-C Bonds by Growth of In-liquid Plasma of Ethanol and Iron Phthalocyanine Mixture**
¹Ryo Hamaji, ¹Tomoki Amano, ¹Hiroki Kondo, ¹Takayoshi Tsutsumi, ¹Kenji Ishikawa, ¹Makoto Sekine, ²Keigo Takeda, ²Mineo Hiramatsu and ¹Masaru Hori
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²Meijo University
- 18P1-29 **Effect of Discharge Current on Phase Transitions in Dusty Plasma in Neon Glow Discharge at Cryogenic Temperature**
Dmitry Polyakov, Valeria Shumova and Leonid Vasilyak
Russian Academy of Sciences
- 18P1-30 **Trial of the Two-dimensional Functional Thin Film Preparation by Sputtering Method using Powder Targets**
¹Hiroharu Kawasaki, ¹Tamiko Ohshima, ¹Yoshihito Yagyu, ¹Takeshi Ihara, ¹Masanori Shinohara And ²Yoshiaki Suda
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²National Institute of Technology, Ishikawa College
- 18P1-31 **Cubic Boron Nitride Film Deposition by Electron Beam Excited Plasma**
¹Seigo Takashima, ¹Susumu Ichimura, ²Hiroyuki Yamamoto, ²Koji Yamakawa, ²Shoji Den, ³Masanao Iwata, ⁴Kenji Ishikawa and ⁴Masaru Hori
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³Iwata Tool Co., Ltd.
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- 18P1-32 **Application of RF Sputtering Prepared CuO Micro-Electro-Mechanical-Systems (MEMS) Gas Sensor**
¹Shao-Yu Fan, ¹Cheng-Liang Hsu and ²Ting-Jen Hsueh
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²National Kaohsiung University of Science and Technology
- 18P1-33 **Dual magnetron sputtering system operating in deep oscillation mode**
Vladimir Oskirko, Viacheslav Semenov, Alexander Grenadyorov, Alexander Zakharov, Artem Pavlov and Andrey Solovyev
Institute of High Current Electronics SB RAS
- 18P1-34 **Deposition of protective and anti-reflection a-C:H:SiO_x films for IR optic**
Alexander Grenadyorov, Konstantin Oskomov, Viacheslav Semenov and Andrey Solovyev
Institute of High Current Electronics SB RAS
- 18P1-35 **Improving P-type Micro-oxidized ZnO:N Film by Efficient Thermal Treatment**
Chiung-Wei Lin, Cheng-Hung Shen and Bing-Ying Zhong
Tatung University

- 18P1-36 **Microwave Plasma Treatment of CVD-Synthesized Single- and Few-Layer MoS₂**
Akihisa Ogino and Masahiro Sugiyama
Shizuoka University
- 18P1-37 **Hydrophilic Functional DLC Coating on an Inner-wall of Artificial Vascular Grafts Using Oxygen Plasma by AC High Voltage Burst Plasma CVD Method**
¹Yuichi Imai, ²Tatsuyuki Nakatani, ³Yasuhiro Fujii and ³Susumu Ozawa
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³Okayama University
- 18P1-38 **Characteristics of ZnO-SnO₂ Thin Film Transistors on Flexible Substrates**
Kazuo Satoh, Shuichi Murakami, Yusuke Kanaoka, Yoshiharu Yamada, Yoshiharu Kakehi, Yusuke Kondo and Yoshiaki Sakurai
Osaka Research Institute of Industrial Science and Technology
- 18P1-39 **Preparation and Characteristics of Al Doped ZnO Films for Transparent Electrode of Photovoltaic Devices by using Low- Damage Sputtering**
Yu Jin Kim, Sangmo Kim and Kyung Hwan Kim
Gachon University
- 18P1-40 **Gate-bias Instability of Amorphous In-Ga-Zn-Ox Thin-film Transistors Fabricated by Plasma-assisted Reactive Processes**
¹Kosuke Takenaka, ¹Masashi Endo, ¹Tomoki Yoshitani, ¹Hiroyuki Hirayama, ¹Giichiro Uchida, ²Akinori Ebe and ¹Yuichi Setsuhara
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- 18P1-41 **Double Conductive Filaments Behavior in the (In, N) co-doped ZnO Resistive Memory Device**
¹Sih-Sian Li, ¹Ricky W. Chuang and ^{1,2}Yan-Kuin Su
¹National Cheng Kung University
²Kun Shan University
- 18P1-42 **Fabrication of Tungsten Carbide Films by Unbalanced Magnetron Sputtering for Electrical Conductive Hard Coating**
¹Koki Tamekuni, ¹Toru Harigai, ¹Satoshi Degai, ¹Tsuyoshi Tanimoto, ¹Yoshiyuki Suda, ¹Hirofumi Takikawa, ²Shigeki Takago, ²Haruyuki Yasui, ³Satoru Kaneko and ⁴Shinsuke Kunitsugu
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- 18P1-43 **Influence of Annealing on Sputtered Boron Nitride Film**
¹Hongshuo Wang, ¹Tadayoshi Sakai, ¹Xu Yang, ¹Manato Deki, ¹Maki Kushimoto, ^{1,2}Atsushi Tanaka, ¹Shugo Nitta, ¹Yoshio Honda and ^{1,2}Hiroshi Amano
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18P1-44 Preparation and Application of Ni-doped CuCo_2O_4 Thin Films

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18P1-45 Development of Repairing Technology for Local Damaged Points of Diamond-Like Carbon Film

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